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# Unusual nonlinear strain dependence of valence-band splitting in ZnO

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Using first-principles band structure calculations, we investigate the crystal-field and spin-orbit splittings at the valence-band edge of ZnO and their dependence on the strain. Different from other conventional semiconductors, the variation of the valence-band splitting of ZnO shows a strong nonlinear dependence on the strain and the slope of the crystal-field splitting as a function of strain can even change sign. Our analysis shows that this unusual behavior in ZnO is due to the strong coupling between Zn 3d states and oxygen 2p states. A mapping of the valence-band ordering in ZnO under different strain levels is provided that will be useful in designing ZnO-based optoelectronic devices.

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## I. INTRODUCTION

Strain can significantly modify the electronic band structure of a material, <sup>1–3</sup> thus it can have strong effects on the structural, electrical, and optical properties of the material. <sup>4–6</sup> Because of this, it has been extensively studied both theoretically and experimentally in the past decades and has often been used in designing electronic devices to enhance the device performance. There are many different ways to apply strain, e.g., by applying external stress, having lattice and/or crystal structure mismatch between the epitaxial film and substrate<sup>4</sup> or between the layers in a heterostructure superlattice, <sup>7</sup> or having reconstructions on a polar surface. <sup>8</sup>

ZnO has great potential for optoelectronic applications such as blue and ultraviolet light sources,  $^{9,10}$  transparent electrodes in electronic circuits,  $^{11}$  and solar cells.  $^{12}$  Recently, there were some attempts to tailor the electrical and optical properties of ZnO through strain.  $^{13,14}$  Surprisingly, despite extensive experimental and theoretical studies on this material, the dependence of the valence-band splitting on the strain for ZnO has not been clearly analyzed yet. The knowledge of the electronic structure properties of ZnO is far from satisfactory, e.g., the size and sign of the crystal-field ( $\Delta_{CF}$ ) and spin-orbit ( $\Delta_{SO}$ ) splitting at the valence band maximum (VBM), which determine the order of the VBM states [ $\Gamma_{9(6)v}$ ,  $\Gamma_{7(6)v}$ , and  $\Gamma_{7(1)v}$ , where the numbers in the parentheses of the subscript are the single group representations, i.e., in the absence of spin-orbit coupling] has been a long standing controversy for more than 50 years (see, e.g., Ref. 15 and references therein).

For most conventional tetrahedrally bonded semiconductors, the lowest state of the conduction band minimum (CBM) is s-like, whereas the upmost states of the valence-band are mainly anion p-like. Therefore, for these materials such as AlN, the band splitting follows the behavior for p states and the electronic states shift almost linearly under strain, which can be described by the deformation potentials b or d. Consequently, the splittings, i.e., the energy level difference between the VBM states, induced by the intraband deformation potentials change quasilinearly as functions of strain.  $^{17,18}$  However, in tetrahedral ( $T_d$ ) symmetry, the cation d and anion p states have the same symmetry representation, so they can

couple to each other. <sup>19</sup> When the *p-d* coupling becomes large in some of the materials such as ZnO, the change of the VBM splitting as a function of strain could be very different than the conventional *sp* semiconductors.

Here, using first-principles band structure calculations, we investigated the electronic band structure of ZnO, especially the crystal-field and spin-orbit splittings at the  $\Gamma$  point valence-band edge as functions of strain. We show that the variation of the valence-band splitting of ZnO with strain is very different from other conventional semiconductors, i.e., it shows a strong nonlinear variation and the slope of the crystal-field splitting as a function of strain can even change sign. After analyzing the structural and electronic properties of ZnO under different strain conditions, we concluded that it is the strong p-d coupling in ZnO that induces this abnormal behavior in the valence-band splitting of ZnO.

#### II. METHOD OF CALCULATION

In our study, all the structural optimizations and energy band calculations are performed using the density-functional theory in the generalized-gradient approximation (GGA).<sup>20</sup> The projected augmented wave method (PAW)<sup>21</sup> as implemented in the VASP (Refs. 22 and 23) code is employed. The energy cutoff is set at 450 eV and an  $8 \times 8 \times 8$  k-point grid is used for structural optimizations. All structures are fully relaxed until the force acting on each atom is less than 0.02 eV/Å.

In this letter, we focus on two types of strains which are the most commonly used in experiments: (1) uniaxial strain applied in the c-axis direction and (2) biaxial strain, i.e., epitaxial strain. For the uniaxial strain case, we fix the lattice constant c at different values, whereas the lattice constant c and the internal cell parameter c are allowed to relax. In this case, strain is defined as  $c_1 = c_{zz} = (c - c_0)/c_0$ . In the case of biaxial strain, c is fixed at several values and the c and c parameters are allowed to relax. The strain is then defined as  $c_2 = c_{xx} = c_{yy} = (a - a_0)/a_0$ . Here, c and c0 are the theoretical equilibrium lattice constants for the unstrained structure.

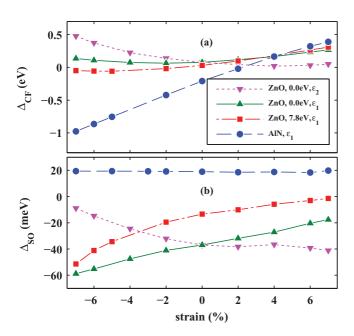


FIG. 1. (Color online) Crystal-field splitting ( $\Delta_{\rm CF}$ ) and spin-orbit splitting ( $\Delta_{\rm SO}$ ) energies of ZnO and AlN under uniaxial ( $\epsilon_1$ ) and biaxial ( $\epsilon_2$ ) strain conditions as functions of the strains, calculated using GGA and LDA + U with  $U_{\rm eff}=7.8$  eV.

#### III. RESULTS AND DISCUSSION

#### A. Crystal-field and spin-orbit splittings versus strain

Figure 1 shows the crystal-field and spin-orbit splittings at the top of valence band in ZnO (triangle lines) under different biaxial and uniaxial strain levels. The crystal-field splitting parameters  $\Delta_{CF}$  are calculated in the absence of spin-orbit interaction,  $\Delta_{CF} = E(\Gamma_{6v}) - E(\Gamma_{1v})$ . The spin-orbit splitting parameters  $\Delta_{SO}$  are obtained by fitting the calculated top three energy levels at  $\Gamma$  to the quasicubic model of Hopfield<sup>24</sup> [with the center of the bands shifted by  $(\Delta_{SO} + \Delta_{CF})/6$ ]:

$$E(\Gamma_{9(6)v}) = 1/2(\Delta_{SO} + \Delta_{CF}),$$
  

$$E(\Gamma_{7(1,6)v}) = \pm 1/2[(\Delta_{SO} + \Delta_{CF})^2 - 8/3\Delta_{SO}\Delta_{CF}]^{1/2}.$$
(1)

We can see that at equilibrium  $\Delta_{CF}$  is positive and  $\Delta_{SO}$  is negative in the GGA calculation, indicating the order of the valence band is  $\Gamma_{7(6)\nu}$ ,  $\Gamma_{9(6)\nu}$ , and  $\Gamma_{7(1)\nu}$ , in decreasing energy. We first look at the case of the system under uniaxial strain condition. From Fig. 1, we can see that when we have tensile strain, both  $\Delta_{CF}$  and  $\Delta_{SO}$  increase as the strain increases. These results are expected because for most sp semiconductors, the  $\Delta_{\rm CF}$  increases with the c/a ratio. However, the situation becomes unusual when compressive uniaxial strain is applied. The change of the  $\Delta_{CF}$  becomes slower and even changes sign and  $\Delta_{CF}$  is always positive no matter how large the strain is. This abnormal behavior is totally different from other more conventional materials such as AlN, which has the same wurtzite structure as for ZnO, see Fig. 1. Because the obvious difference between these two kinds of materials in their electronic structures, i.e., the different positions of the cation d orbitals (Al 3d is extravalence states, whereas Zn 3d is subvalence states), we may attribute these phenomena to the p-d hybridization at the valence-band edge, which are

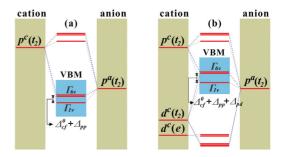


FIG. 2. (Color online) Schematic plot of valence-band splitting in wurtzite semiconductors: (a) without d and (b) with d.  $\Delta^0_{cf}$  denotes the crystal-field splitting induced by Coulomb potential.  $\Delta_{pp}$  and  $\Delta_{pd}$  represent the contributions from p-p and p-d couplings, respectively.

permitted in tetrahedron environment, see Fig. 2. p-d coupling (through a matrix element  $V_{pd}$ ) mixes d character into the wave function at the VBM, and makes some difference in energy to the states. One can estimate the magnitude of these effects as  $\Delta E_{pd} \sim V_{pd}^2/(\varepsilon_p^a - \varepsilon_d^c)$ , in which,  $\varepsilon_p^a - \varepsilon_d^c$  means the state-energy difference, indicating that the *p*-like states at the edge of the valence band have different strength of p-d coupling, i.e., different d component (e.g.,  $\Gamma_{6v}$  is a pure p-d hybridized state but  $\Gamma_{1v}$  has mixed in some s orbitals, and strain may redistribute the d component in the relative states), and hence affect the splitting energies. The negative  $\Delta_{SO}$  also can be attributed to the large d orbital component at the top of the valence band, since d states contribute with opposite sign to the spin-orbit splitting (lowering it), as opposed to porbitals (which raise it).<sup>19</sup> The increase of the volume reduces the p-d coupling at the VBM as the strain increasing, which explains why the  $\Delta_{SO}$  becomes less negative. A similar but opposite trend is also observed when biaxial strain is applied. In this case, even the  $\Delta_{SO}$  is nonlinear under tensile strain. The opposite behavior of biaxial versus uniaxial strain can be understood by noticing that ZnO has positive Poisson ratio, i.e., in the compressive biaxial strain case, there is an elastic expansion of the lattice perpendicular to the strain direction, so c/a increases, whereas for in-plane tensile strain the c/adecrease, opposite to the uniaxial strain case. The relationship between the strain along and perpendicular to the c direction is  $\epsilon_{zz} = -R^B \epsilon_2$  with  $R^B = 2C_{12}/C_{33}$ . For simplicity and representative, in most parts of this letter we just present the results of uniaxial strain case.

Because our calculated GGA values of  $\Delta_{\rm CF}$  and  $\Delta_{\rm SO}$  for equilibrium ZnO are 77 and -36 meV, respectively, are much larger than the experimental results (41.7 and -8.0 meV), one may question whether the density functional theory (DFT) is able to describe this phenomena correctly because it is known that DFT places the Zn 3d band at a too high energy, thus overestimates the p-d hybridization and incorrectly describes the splitting at the VBM. To test this, we use the so-called LDA + U method  $^{26}$  to adjust the position of the Zn 3d energy levels to be close to experimental values. Following Solovyev and Laskowski, we use a spherically symmetric formulation of the LDA + U approach and used the effective  $U_{\rm eff} = U - J = 7.8$  eV. The crystal-field splitting and spin-orbit splitting energies of ZnO as functions of  $U_{\rm eff}$  as well as the density of states resulting from the LDA + U

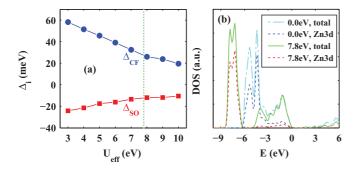


FIG. 3. (Color online) (a) Crystal-field splitting ( $\Delta_{CF}$ ) and spin-orbit splitting ( $\Delta_{SO}$ ) energies of ZnO as functions of  $U_{eff}$ ; (b) Density of states (DOS) of ZnO calculated with GGA and LDA + U. The energy of the VBM is set to be zero.

calculations are presented in Fig. 3. We find that both the magnitudes of crystal-field  $\Delta_{CF}$  and spin-orbit splitting  $\Delta_{SO}$ decrease monotonically and nearly linearly as a function of increasing  $U_{\rm eff}$ , i.e., decreasing in Zn-3d orbital energy. For  $U_{\rm eff} = 7.8$  eV, The calculated results  $\Delta_{\rm CF} = 31$  meV and  $\Delta_{SO} = -13$  meV are in good agreement with the experimental values. The results can be easily understood by noticing that for wurtzite structure the  $\Gamma_{6v}$  is a pure p-d hybridized state but  $\Gamma_{1v}$  has mixing with some s orbitals, so the p-d coupling for the  $\Gamma_{6v}$  state is larger than the  $\Gamma_{1v}$  state. Therefore, when p-d coupling decreases with increasing  $U_{\rm eff}$ , the crystal-field splitting  $\Delta_{CF} = E(\Gamma_{6v}) - E(\Gamma_{1v})$  also decreases. Reducing p-d coupling also reduces the d component at the VBM, so the spin-orbit coupling also becomes less negative. These analyses are consistent with the calculated density of states showing that at  $U_{\text{eff}} = 7.8 \text{ eV}$  the d character in the VBM states is considerably reduced as compared to the pure GGA calculations and the Zn 3d peak has moved down in energy

with an average position of about  $-7 \, \mathrm{eV}$ , which agrees with the experimental value of about  $-6.95 \, \mathrm{eV}$ . These results indicate that using LDA + U method would significantly improve the accuracy of the calculations of valence-band splitting, so in the following analysis, all the results are obtained from the LDA + U method.

Using the LDA + U approach, we calculated again the crystal-field and spin-orbit splittings of the ZnO under different uniaxial and biaxial strain conditions (only uniaxial case is shown in Fig. 1). We find that the general trend is the same as in the GGA calculation, i.e., the nonlinear variations still exist in the valence-band splitting as the strain varies. As a function of strain, the crystal-field splitting now can be negative under some large strain conditions. However, for any reasonable  $U_{\rm eff}$  parameter, at zero strain, the crystal-field splitting is always positive and the spin-orbit splitting is always negative because the p-d coupling in this system is significant and the positive contribution of the spin-orbit coupling due to oxygen p orbital is very small. <sup>19</sup> Therefore the band order at the VBM should be  $\Gamma_{7(6)v}$ ,  $\Gamma_{9(6)v}$ , and  $\Gamma_{7(1)v}$ , in decreasing energy, in agreement with experiment results. <sup>25</sup>

# B. Crystal-field and spin-orbit splittings versus structural parameters

To unveil the underlying physics and understand more about these nonlinear variations of the valence-band splitting in ZnO, we examined the crystal-field and spin-orbit splittings as functions of the structural parameters: volume (V),  $\eta = c/a$  ratio, and the internal structure parameter u independently [u specifies the bond length  $d_1 = uc$  along the c axis, see the inset in Fig. 4(a)], as the structure of the wurtzite is defined by these parameters. Figures 4(a)-4(c) show the three structure parameters V,  $\eta$ , and u as functions of uniaxial strain. We

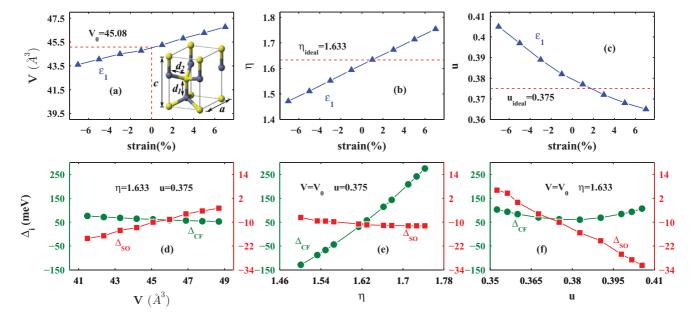


FIG. 4. (Color online) (a)–(c) The volume V, ratio  $\eta = c/a$ , and the internal structure parameter u as functions of uniaxial strain; (d)–(f) Crystal-field splitting ( $\Delta_{CF}$ ) and spin-orbit splitting ( $\Delta_{SO}$ ) as functions of V,  $\eta$ , and u, independently, i.e., (d) V varies,  $\eta$  and u are fixed at 1.633 and 0.375, respectively; (e)  $\eta$  varies, u is fixed at 0.375 and v is fixed at the value of strain free case,  $v_0$ ; (f) v varies, v is fixed at 1.633 and v is fixed at v0.

see that both V and ratio  $\eta$  decrease when the strain is more compressive. It is interesting to see that u parameter increases under compressive strain. This is because to reduce the internal strain, the system tends to preserve the bond length. Therefore, when the c parameter decreases, to preserve the bond length, the u parameter will increase. In general, the structural parameters show the normal behavior of linear dependence under strain.

Figures 4(d)-4(f) give the crystal-field and spin-orbit splitting energies versus V,  $\eta$ , and u, respectively. It is clear that the crystal-field splitting is very sensitive to the change of  $\eta$ , while the spin-orbit splitting is mainly influenced by the change of u. The dependence of the  $\Delta_{CF}$  and  $\Delta_{SO}$  show the quasilinear dependence as a function of V or  $\eta$ . When V decreases, the increased p-d coupling enhances the  $\Delta_{CF}$ but makes  $\Delta_{SO}$  more negative, as discussed earlier. This is partially canceled by the p-p coupling between the oxygen 2p and Zn 4p orbitals. When  $\eta$  increases with fixed V and u, the Coulomb potential induced splitting on the p orbital makes  $\Delta_{CF}$  increase. In this case, the bond length along the c direction is larger than the bond lengths away from the c direction, so the reduced p-d coupling in the c direction and increased p-d coupling away from the c direction also make  $\Delta_{\rm CF}$  increase. The additive nature is the origin of why  $\Delta_{\rm CF}$ is sensitive to the change of  $\eta$ . Because there are three bonds away from the c direction, whereas only one bond along the c direction, the spin-orbit splitting  $\Delta_{SO}$  decreases as  $\eta$  increases. Contrary to the dependence on V and  $\eta$ , we find that for ZnO, the crystal-field splitting  $\Delta_{CF}$  has a strong nonlinear dependence on u. The slope changes sign at a critical point  $u_c$  and the curve is almost quadratic. This is because when u increases at fixed V and  $\eta$ , the bond length along the c direction increases and the bonds away from the c direction decrease. Therefore both p-p and p-d coupling decrease along the *c* direction [associated with the  $E(\Gamma_{1v})$ ] but increase away from the c direction [associated with the  $E(\Gamma_{6v})$ ]. However, the effect of p-p and p-d coupling is opposite. For most conventional semiconductors, p-p coupling is dominant, so  $\Delta_{CF}$  will decrease as u increases, but for ZnO with large p-d coupling, for large u,  $\Delta_{CF}$  increases.  $\Delta_{SO}$  decreases with uagain because there are more bonds away from the c direction than along the c direction. Combining the changes of the structural parameters and the dependence of the  $\Delta_{CF}$  and

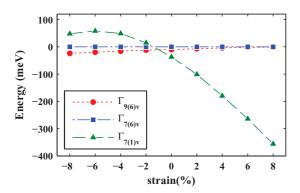


FIG. 5. (Color online) The valence-band ordering of ZnO under different levels of uniaxial strain. The energies of  $\Gamma_{7(6)v}$  band are set to be zero.

TABLE I. The projected wave function characters of the  $\Gamma_{6v}$  and  $\Gamma_{1v}$  states (electron numbers) at the Zn site.

band	u	$p_x + p_y$	$p_z$	$d_{xy} + d_{x^2 - y^2}$	$d_{xz} + d_{yz}$	$d_{z^2}$
$\Gamma_{6v}$	0.356	0.012	0.000	0.108	0.080	0.000
	0.368	0.016	0.000	0.124	0.071	0.000
	0.379	0.022	0.000	0.140	0.061	0.000
	0.390	0.028	0.000	0.158	0.053	0.000
	0.402	0.034	0.000	0.175	0.044	0.000
$\Gamma_{1v}$	0.356	0.000	0.046	0.000	0.000	0.215
	0.368	0.000	0.032	0.000	0.000	0.201
	0.379	0.000	0.020	0.000	0.000	0.184
	0.390	0.000	0.010	0.000	0.000	0.164
	0.402	0.000	0.004	0.000	0.000	0.141

 $\Delta_{SO}$  on the structural parameters, we can explain the results observed in Fig. 1.

Our discussion above suggests that the nonlinear variation of crystal-field splitting  $\Delta_{\rm CF}$  with the strain can be attributed to the change of internal structure parameter u, namely, internal strain due to a competition between the p-p and p-d couplings caused by the structural change. To further confirm this, we analyze the characters of partial charges at Zn muffin-tin site of the  $\Gamma_{6v}$  and  $\Gamma_{1v}$  states (see Table I). When u increases, bond length  $d_1$  (axial bond) elongates and  $d_2$  (nonaxial bond) shrinks [inset in Fig. 4(a)]. As a result, the p-d coupling in the xy-plane is strengthened, while in the z direction becomes weaker. For  $\Gamma_{6v}$  states, the total p-d coupling is getting stronger as u increases (Table I,  $d_{xy} + d_{x^2-y^2}$  increases,  $d_{xz} + d_{yz}$  decreases and the total increases). This is consistent with our above analysis.

### C. Valence-band ordering

Finally, Fig. 5 shows the valence-band ordering of ZnO under different levels of uniaxial strain calculated with LDA + U. It shows that, at strain-free conditions, the upmost state possesses  $\Gamma_7$  symmetry resulting in a level ordering  $\Gamma_{7(6)v}$ ,  $\Gamma_{9(6)v}$ , and  $\Gamma_{7(1)v}$ , which is in agreement with most of theoretical calculations and experimental results. A band crossing mainly caused by crystal-field splitting will occur at a certain compressive strain, with a consequence of the change of the valence-band ordering from  $\Gamma_{7(6)v} - \Gamma_{9(6)v} - \Gamma_{7(1)v}$  to  $\Gamma_{7(1)v} - \Gamma_{7(6)v} - \Gamma_{9(6)v}$ . In addition, for not too large strains, such as in our calculations, from -8% to 8%, the  $\Gamma_{7(6)v}$  state is always above the  $\Gamma_{9(6)v}$  state due to the negative spin-orbit splitting.

#### IV. CONCLUSIONS

We have examined several other Zn chalcogenides, such as ZnS, ZnSe, and ZnTe, and obtained similar results. However, as the *p-d* reduces as the anion size increases, the nonlinear relationship in the valence-band splitting of the zinc chalcogenides also diminishes.

In summary, we have investigated the valence-band splitting of ZnO and its strain dependence using first-principle calculations. We found that due to large *p-d* coupling in ZnO, it exhibits unusual behavior, i.e., the variation in valence-band

splitting versus strain is strongly nonlinear. Based on our theoretical study, we presented the valence-band ordering in ZnO under different strain conditions. The mechanism and the underlying physics unveiled in the present work provided new insights on the understanding of semiconductor band structures and should be very useful in applying strain to enhance the device performance by modifying the band structures in designing electronic and optical devices.

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